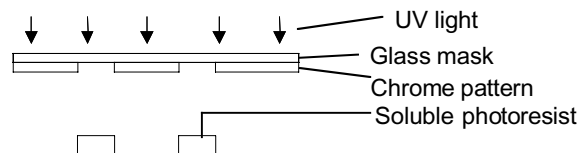


ERRATA 08/25/2003

PLEASE SEND ANY OTHER ERRATA TO res@ece.ubc.ca.

1. p. 93 — the soluble photoresist extends further than appropriate. The correct figure is



Step 3: Pattern photoresist with
UV light through glass mask

2. p 123 — $d=4$ should be replaced with $pd=4$ in the SPICE line for mp
3. p 126 — $s=8$ should be replaced with $as=8$ in the SPICE line for mp
4. p. 162 — Figure 4.10(c) is missing a V_{IL} label in the graph
5. p. 173 — near the bottom of the page, replace $V_{out}=V_{OUI}$ with $V_{out}=V_{OUH}$.
6. p. 174 — near the bottom of the page, replace $V_{out}=V_{OUH}$ with $V_{out}=V_{OUH}$.
7. p. 187-188 — Figures P4.1 and P4.2 should be reversed.